

DOCKET NO: 210136US99



IN THE UNITED STATES PATENT & TRADEMARK OFFICE

IN RE APPLICATION OF :
RAVINDRANATH DROOPAD ET AL : EXAMINER: BAUMEISTER
SERIAL NO: 09/901,109 :
FILED: JULY 10, 2001 : GROUP ART UNIT: 2815

FOR: STRUCTURE AND METHOD FOR :
FABRICATING SEMICONDUCTOR
STRUCTURES AND DEVICES
UTILIZING THE FORMATION OF A
COMPLIANT SUBSTRATE COMPRISING
AN OXYGEN-DOPED COMPOUND
SEMICONDUCTOR LAYER

AMENDMENT

COMMISSIONER FOR PATENTS
ALEXANDRIA, VIRGINIA 22313

SIR:

Responsive to the Official Action dated June 20, 2003, Applicants respectfully
request reconsideration in view of the following amendment and remarks.

The Claims begin on page 2 of this paper.

Remarks/Arguments begin on page 3 of this paper.

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TECHNOLOGY CENTER 2800